Training and Validation of a Wide-angle Optical Scattering (TAOS) Pattern Classifier

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Abstract— TAOS (two-angle optical scattering) is a well-known experimental technique which records the intensity patterns of laser light scattered by single aerosol particles over an extended range of the scattering angles $\{\theta,\phi\}$ [1]. In the absence of a method which solves the inverse obstacle problem from intensity data, patterns have to be classified by artificial intelligence techniques. The classifier described herewith extracts features from TAOS patterns by the spectrum enhancement algorithm [2], which is controlled by a few parameters (the n-tuple ψ), not described herewith. Training corresponds to finding a ψ which maximizes a suitable figure of merit (F). The newly developed training-validation scheme is illustrated by the following example. 1) Out of 100 TAOS patterns produced by clusters of polystyrene spheres of controlled size (material a6, class 1) and 100 patterns from single spores of $Bacillus\ globigii$ (material bg, class 2), form e.g., 10 training (T) sets of 50 patterns from each class, which differ by at least 5+5 patterns from one another. Two sample patterns are shown by Figures 1 and 2 below.





Figure 1: Scattering pattern of a polystyrene (PS) sphere aggregate (class 1).

Figure 2: Scattering pattern of Bacillus globigii (Bg) spores. (class 2).

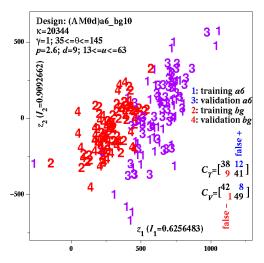


Figure 3: Classifier output: representation of TAOS patterns on the plane of the first two principal components z_1, z_2 . To each pattern there corresponds a point on $\{z_1, z_2\}$. Patterns are labeled after their class of belonging and role in either T- or V-mode. The parameters γ , p, d and the endvalues of both θ and u form the n-tuple ψ ; u is the spatial wavenumber on which enhanced spectra depend. I_1 , I_2 are the fractions of sample variance explained by z_1 alone and by z_1 and z_2 together. C_T and C_V are the T- and V-mode confusion matrices. A "false-" (false negative) is a misclassified bg pattern.

2) Evaluate $F[\psi]$ for all available ψ and all T-sets, keep those ψ such that $F[\psi] > \tau$, a threshold value. 3) Select a ψ which minimizes $H[\psi] := -\Sigma_{\psi} \ln[f[\psi]] F[\psi]$, where $f[\psi]$ is the relative frequency by which $F[\psi]$ occurs. 4) Use the leftover patterns for classifier validation (V).

Figure 3 displays the classification result which corresponds to F=0.824 in training (T) and F=0.883 in validation (V) mode. The eventual goal is to implement a realtime TAOS pattern classifier.

REFERENCES

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